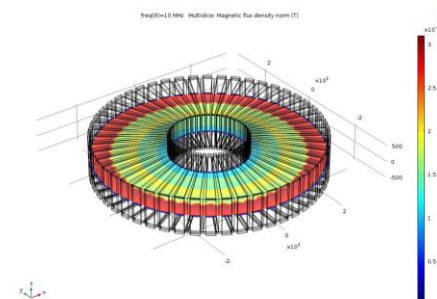
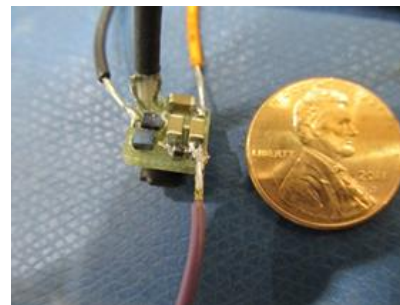
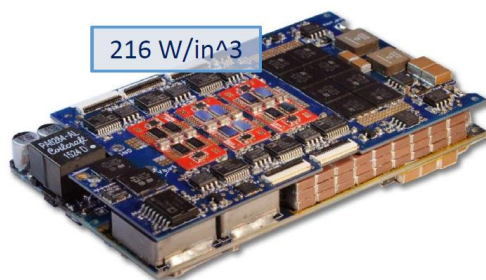
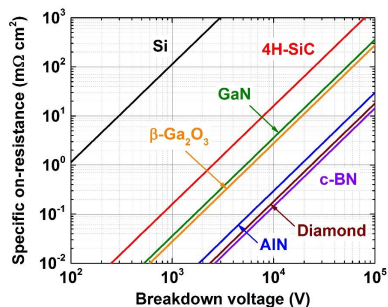


*Exceptional service in the national interest*



## New Ideas for SSL: Integration of III-N LEDs and Power Electronics

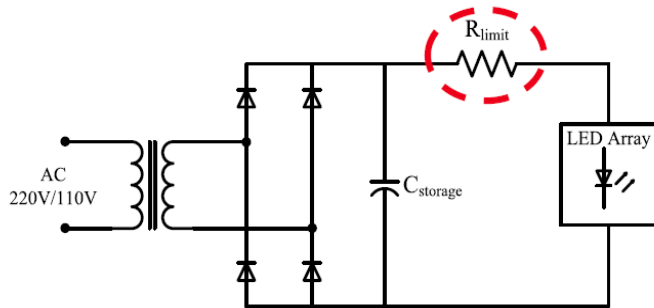
Bob Kaplar and Greg Pickrell, Sandia National Labs

DOE SSL Roundtable

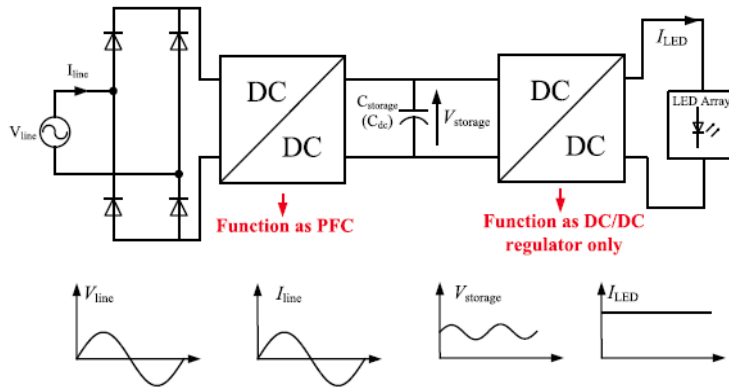
August 31, 2017

# SSL Drivers and Potential Advantages of Integration

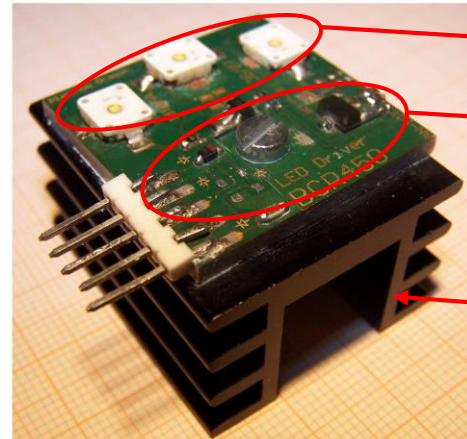
Passive converter



Two-stage switching converter



S. Li et al., Trans. Power Elec. 31(2), 1503 (2016)



III-N LEDs

Discrete Si  
drive circuitry

Heatsink

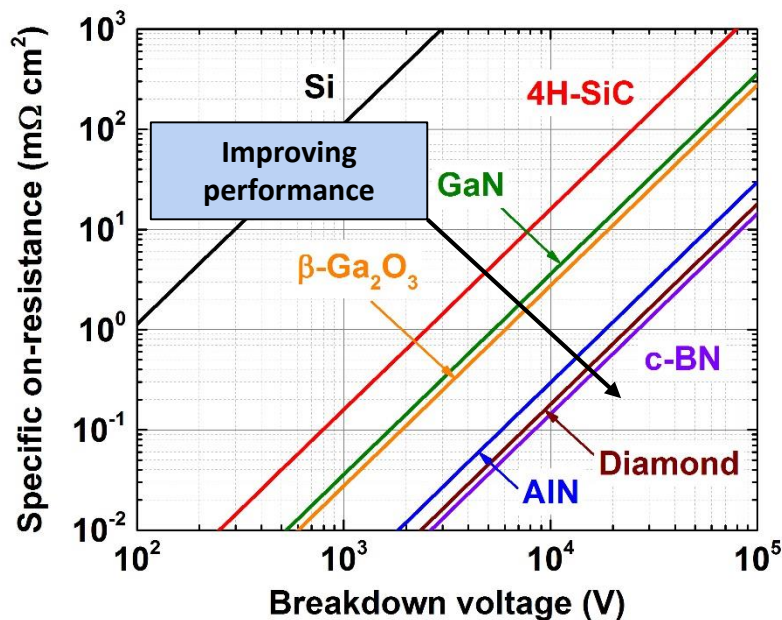
Infineon application note 105

## Integration may be advantageous if:

- Small volume and/or high efficiency (low loss = reduced thermal management) are paramount
- Enhanced functionality requiring complex circuitry is required
- Some tolerance for higher cost exists (at least initially – cost may ultimately be lower in the long term)

# GaN Power Electronics

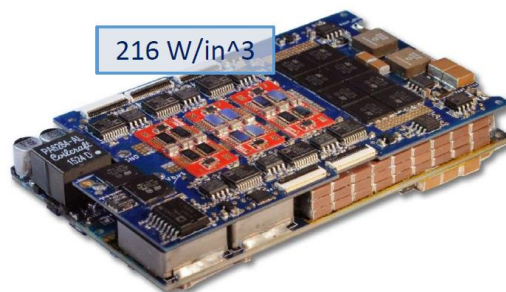
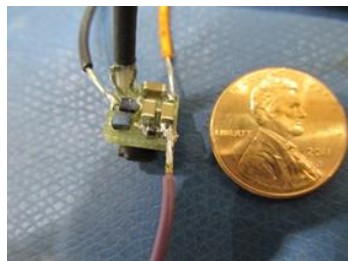
$$\text{Unipolar FOM} = V_B^2 / R_{\text{on,sp}} = \epsilon \mu_n E_C^3 / 4$$



J. Y. Tsao et al., Adv. Elec. Mat. (in press)

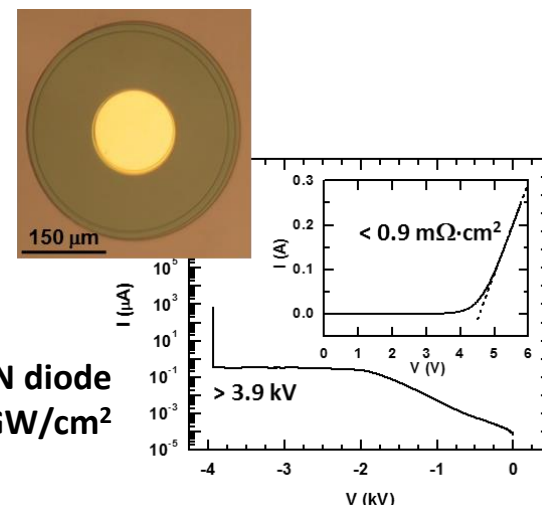
SNL "Coin Converter"  
using GaN HEMTs:  
90 V, 90 mA  $\rightarrow$  215 W/in<sup>3</sup>

J. Neely



UIUC multi-level flying-capacitor converter using GaN HEMTs:  
2 kW, 216 W/in<sup>3</sup>, > 97% peak efficiency

Y. Lei et al., APEC 2016



SNL vertical GaN PiN diode  
UFOM = 18 GW/cm<sup>2</sup>

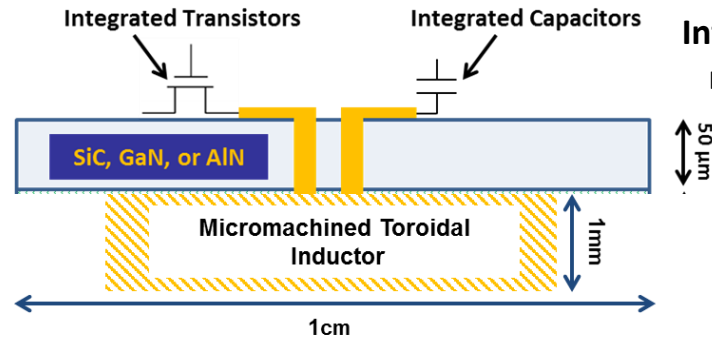
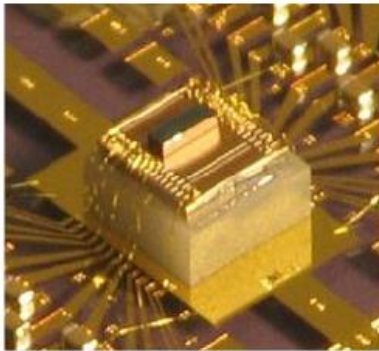
A. Armstrong et al., Elec. Lett. 52(13), 1170 (2016)



# Different Approaches to Integration: Package (Module) and Chip Levels

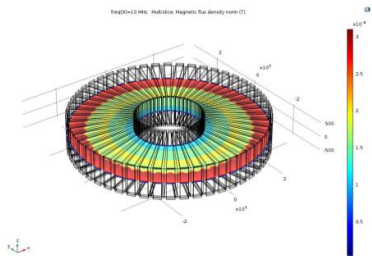
## Heterogeneous integration of III-V optoelectronics and Si CMOS

A. Tauke-Pedretti, SNL



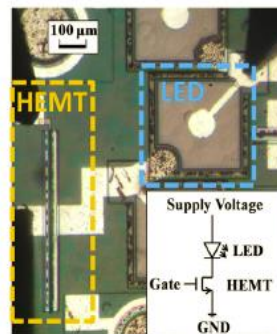
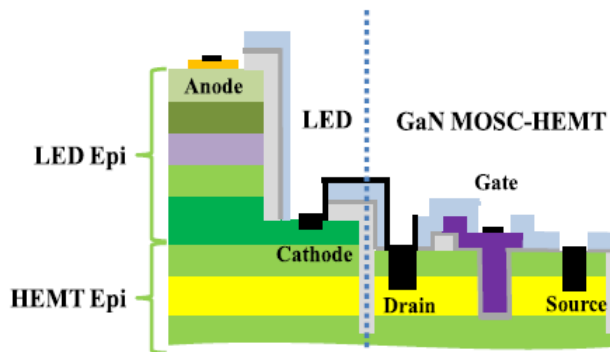
## Integration of micromachined nanocomposite magnetics

T. Monson, SNL



## Chip-scale integration of GaN LED and HEMT (RPI)

Z. Li et al., Appl. Phys. Lett. 102, 192107 (2013)



## Chip-scale integration of GaN power and gate drive HEMTs (Navitas)

M. Giandalia, APEC 2016

